

Defect memo

Change in refractive index (due to displacement of dopants) can also cause absorption. Scattering can induce loss.

Griscom 1991 :

- **Electron Spin Resonance (ESR) spectrometry:** measure paramagnetic defects → Griscom, 1991. Intrinsic paramagnetic centers so far identified by ESR :
 - E' centers ($\equiv Si \cdot$)
 - Non-bridging oxygen hole centers ($\equiv Si - O \cdot$)
 - Peroxy radicals ($\equiv Si - O - O \cdot$)
 - Self-trapped holes (\cdot)

"Each defect has its own distinctive ESR "signature". Thus, if a suitably strong correlation can be established between an optical band and a well characterized ESR signal, then it can be said that one likely source of the band has been identified."

Intrinsic diamagnetic defects not identified:

- Neutral oxygen vacancy ($\equiv Si - Si \equiv$)
- 2-coordinated Si ($-O - Si - O -$)
- Peroxy linkages ($\equiv Si - O - O - Si \equiv$)

Possibility of diamagnetic trapped-electron centers. Other trapped-electron center also believed to exist is O_2^- molecular ion (paramag but may not be ESR observable)

Also extrinsic defects due to impurities, hydroxyl (particularly to water radiolysis which can play an important role on post-irradiation growth and decay kinetics if ≥ 100 ppm OH in glass) and chloride. → color centers

Girard 2019:

- Nice table with defects and absorption bands
- Three main effects that can affect the fiber transmission : Radiation Induced Attenuation (RIA), Radiation Induced Emission (RIE) and Radiation Induced Refractive Index Change (RIRIC)
 - RIRIC is said to have a big importance under neutron exposure

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Type of defect	Study (exp tool)	Absorption peak (eV)	Notes
E' centers ($\equiv Si \cdot$)	ESR (Griscom 91)	5.8 (0.7) (Gi19)	Paramagnetic Unpaired spin in dangling tetrahedral orbital. Located at the oxygen vacancy (G91) % influenced by fiber drawing Formation energy $\sim 3.8eV$ Broken bond picture rather than vacancy \neq types: $E_\beta, E_\delta, E_\gamma, E_\alpha$ (depending on formation mech)
Non-bridging oxygen hole centers ($\equiv Si-O\cdot$) NBOHC	ESR (Griscom 91)	1.97 (0.17) 4,8 (1.0) 6.4 (1.7) ^① (Gi19)	Paramagnetic Can come from fission of strained OSi bond (could also interact with other -> charge), from radiolysis of hydroxyl (this one can be observed with ESR)
Peroxy radicals ($\equiv Si-O-O\cdot$) POR	ESR (Griscom 91)	2.02, 4.08, 5.02, 2.0, 4.8 (Gi19)	Paramagnetic
Self-trapped holes $2 \neq: Si-\dot{O}-Si$ (STH1) or \cdot delocalized on 2 bridging O (STH2)	ESR (Griscom 91)	STH1 : 2.61 (1.2) + 1.88 (0.2-0.5) (Gi19) STH2 : 2.16 (0.3-0.6) 1.63 (0.3-0.7)	Paramagnetic Begin to bleach above 130K and disappear at around 200K
<i>LTRIA</i> (<i>STH</i>)		0.6-0.7 (non-Gaussian) (Gi19)	
Neutral oxygen vacancy ($\equiv Si-Si \equiv$) = ODC(I)		7.6 (0.5–06) (Gi19)	Diamagnetic
ODC(II) ($> Si:$)		5.05 (0.32) and 3.15 (0.30) ^① 6.9 (0.4) (Gi19)	
2-coordinated Si ($-O-Si-O-$)			Diamagnetic
Peroxy linkages ($\equiv Si-O-O-Si \equiv$) POL		3.8(0.2), 4.2(0.6), 7.3(0.2), 7.5(0.1) (Gi19)	Diamagnetic
Self-trapped Electron (STE)		3.7, 4.6, 6.4 (Gi19)	Not presented in G91
Self-trapped Exciton (STEX)		4.2 (1.16) 5.3 (0.78) (Gi19)	Not presented in G91
Impurities		In the 160-200nm (G91)	
Ozone (O_3)		4.8 (0.8–0.86) (Gi19)	
O_2		0.97 (0.013) 1.62 (0.013) (Gi19)	
ClO		3.26 3.65 (Gi19)	
Cl^2		3.78 (0.6) 2.3 (Gi19)	
$H(I)$ ($> Si^* - H$)		Not observed (Gi19)	

Appendix:

- GRISCOM 91:

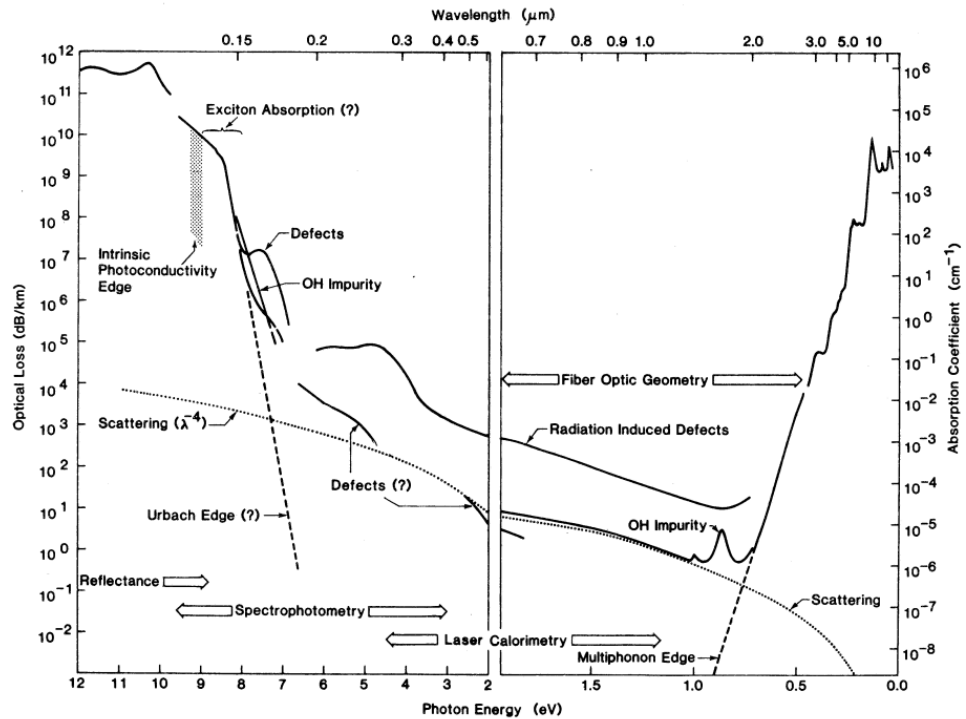


Fig. 1. Optical attenuation spectra of pure fused silica. Radiation-induced spectrum pertains to Suprasil W1. Sources of the original data are cited in Ref. 14.

- GRISCOM 85:

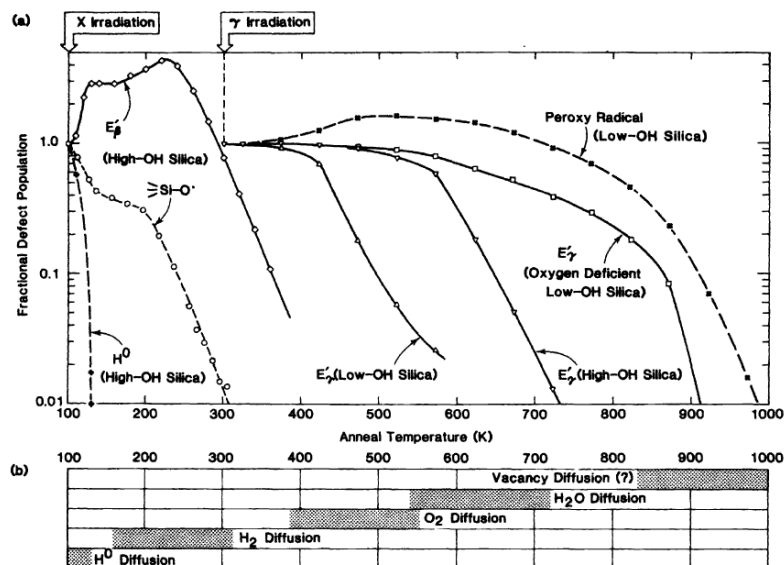


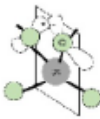
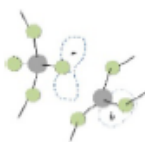


Fig. 5 (a) Isochronal anneal curves (5-10 min anneals) for radiation-induced defect centers in high purity Type-III (1200 ppm OH) and Type IV (< 5 ppm OH) fused silicas and (b) effective temperature ranges for various diffusion-limited anneal mechanisms, after Ref. 31.

Thermally activated post-irradiation processes in a-SiO_2

Table 1
Review of the main optical properties of pure-silica related point defects and those related to chlorine and hydrogen impurities.

Name	Structure	Param	OA peak eV (FWHM eV)	Oscillator strength	Note	PL peak eV (FWHM eV, lifetime RT)	Refs
Oxygen deficient center	>Si:	No	5.05 (0.32)	0.15	S ₀ -S ₁ transition ISC assisted (T ₁ -S ₀ transition)	4.4 (0.4 eV; 4.0 ns)	[16,29,156–159]
ODC(II)			3.15 (0.30) [Ⓐ]	1.60 10 ⁻⁷	S ₀ -T ₁ transition	2.75 (0.34; 10 ms)	[16,139,157,159–162] [16,121,163–169]
ODC(I)		No	6.9 (0.4)	0.1–0.2	PL features similar bands	2.75(0.34; 10 ms)	
Non-Bridging Oxygen Hole Centers		Yes	7.6 (0.5–0.6)	0.1–0.2		4.4 and 2.7	
NBOHC		Yes	1.97 (0.17)	1.90 10 ⁻⁴	Asymmetric Pekarian-shaped	4.4 (0.4 eV, 1.4 ns)	
E'		Yes	4.8 (1.0)	0.05	5 Gaussian are needed to describe the absorption in UV VUV	1.91 (0.17, 10–20 μs)	[16,156,170–172] [173–180] [173,177,178]
Self-trapped hole STH ₁		Yes	6.4 (1.7) [Ⓐ]	0.05	see ref [167] for the relative intensity	Not observed	
		Yes	5.8 (0.7)	0.1–0.2	Inherent	None reported	
STH ₂		Yes	2.61 (1.2)	0.283 [Ⓐ]	Strain-assisted (observed in OF)	None reported	[173–180] [173,177,178]
		Yes	1.88 (0.2–0.5)			None reported	
Peroxy Linkage POL	Si-O-O-Si	No	2.16 (0.3–0.6)	0.283 [Ⓐ]	Inherent	None reported	[173–180] [173,177,178]
Peroxy Radical POR	Si-O-O•	Yes	1.63 (0.3–0.7)		Strain-assisted (observed in OF)	None reported	
Self-trapped Electron STE			3.8(0.2), 4.2(0.6, 7.3(0.2), 7.5(0.1)	~0.0005–0.003	Computational	None reported	[30]
Self-trapped Exciton STEX		Yes	2.02, 4.08, 5.02	0.00056, 0.052, 0.035	Computational (one SiO ₄ H-passivated tetrahedron cluster)	–	
			2.0, 4.8	0.0004, 0.2	experiment	–	
		No	3.7	–	Computational	–	
			4.6	–	Computational	–	[173,182] [173,182] [173,182] Theory [183] Exp [184–189]
			6.4	–	Computational	–	
			4.2 (1.16)	–	Computational	2.85 eV (theory)	
			5.3 (0.78)	–	Experimental	2.6 – 2.8 eV (exp)	
Ozone	O ₃		4.8 (0.8–0.86)	Cross section 1.2 10 ⁻¹⁷ cm ²	VUV UV bleaching can induce the O ₂ emission [21]		[190,191]
O ₂	molecular oxygen	Yes	0.97 (0.013)	1.1 10 ⁻⁸	T ₁ -S ₀ transition	0.97 (0.01 eV, 0.4–0.8 s) [Ⓐ]	[192–198]
ClO	ClO	Yes	1.62 (0.013)	4.2 10 ⁻⁹	T ₁ -S ₁ transition	–	[88,177,199,200] [122]
Cl ²	Cl ²	No	3.26	–	–	–	
			3.65	–	–	–	
H(I)	>Si'-H	Yes	3.78 (0.6)	3.8 cross section 2.58 10 ⁻¹⁹ cm ²	Vibronic progression T < 110 K	1.2 (0.42, 5 ms at 13 K)	[14,17,23] [153]
LTRIA	STH	Yes	2.3	–	–	Not observed	
		Yes	0.6 – 0.7 eV (non-Gaussian)	–	LTRIA is attributed to inherent STHs	Not observed	

[Ⓐ] Peak and FWHM derived from PLE spectra.
[Ⓐ] Linear combination Gaussian bands peaking at 2.16 and 2.60 eV.
[Ⓐ] Strong radioluminescence signal under X-rays [103].